

INFORMATION DISCLOSURE CITATIONS IN AN APPLICATION

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APR 29 2004

Document Number (Continuation)

TSMC-02-262 CIP

Applicant Number

10/808,801

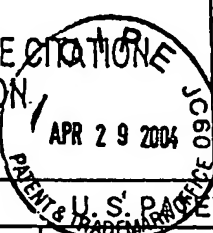
Applicant

Tien-I. Bao et al.

Filing Date

03/24/04

Group Art Unit



U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	TITLE	CLASS	SUBCLASS	PUB. DATE IF APPROPRIATE
IA	6365320	4/2/02	Foot et al.	430	270.1	1/19/99
	6376392	4/23/02	Lee et al.	438	778	5/18/01
	6159871	12/12/00	Loboda et al.	438	786	5/29/98
	5926740	7/20/99	Forbes et al.	438	763	10/27/97
	6121130	9/19/00	Chua et al.	438	623	11/16/98
	6168726	1/2/01	Li et al.	216	79	11/25/98
	6372661	4/16/02	Lin et al.	438	769	7/14/00
IA	6054379	4/25/00	Yau et al.	438	623	2/11/98

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation YES NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

IA	-	US Patent App. Pub. US 2003/0134495A1 to Gates et al., Pub. Date 07/17/03, Filed 01/15/02, U.S.-Cl. 438/600.

EXAMINER

DATE CONSIDERED

5/27/05

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.